

Title (en)

METHOD FOR THE PREPARATION OF SYNTHETIC QUARTZ GLASS WITH THE USE OF A CLEANING DEVICE

Title (de)

VERFAHREN ZUR HERSTELLUNG VON SYNTHETISCHEM QUARZGLAS UNTER VERWENDUNG EINER REINIGUNGSVORRICHTUNG

Title (fr)

PROCÉDÉ DE FABRICATION DE VERRE DE QUARTZ SYNTHÉTIQUE À L'AIDE D'UN DISPOSITIF DE PURIFICATION

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Application

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Abstract (en)

[origin: WO2016096811A1] The present invention relates to a method for producing synthetic quartz glass using a specific cleaning device, to an apparatus for producing synthetic quartz glass, comprising a specific cleaning device, to the use of a packed bed of porous silica particles for cleaning a vaporous feedstock to produce synthetic quartz glass, and to the synthetic quartz glass obtained according to the method of the invention.

IPC 8 full level

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